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Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L17	149	((wafer or substrate or semiconductor or workpiece or electronic\$8) near15 (rotated or rotating or rotate or spin or spinning or rotor or centrifug\$8) near15 (water or liquid or rins\$8 or wash or washing or washer or clean\$8 or decontaminat\$8 or immers\$8 or souc\$8 submerg\$8 or bath)) and (("o.sub.3" or ozon\$8) near15 (gas or atmosphere or environment or gaseous or nebuliz\$8 or vapor or fog or aerosol) near15 (hot or heat or heater or heated or heating or temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 23:13